

# Evaluation of byproduct formation and toxicity change during drinking water treatment with UV/H<sub>2</sub>O<sub>2</sub> and UV/Chlorine using *in vitro* bioassays combined with chemical analysis

#### Hyunjin Kim<sup>1</sup>. Sin-Yi Liou<sup>1</sup>. Yegyun Choi<sup>1</sup>. Heejong Son<sup>2</sup>. Yunho Lee<sup>1\*</sup> (yhlee42@gist.ac.kr)

School of Earth Science and Environmental Engineering<sup>1</sup>, Gwangju Institute Science and Technology (GIST), 123 Cheomdan-gwagiro, Buk-gu, Gwangju 61005, Republic of Korea Busan Water Quality Institute<sup>2</sup>, 691 Dongbuk-ro, Sangdong-myeon, Gimhae-si, Gyeongsangnam-do 50804, Republic of Korea

#### Introduction

UV/H<sub>2</sub>O<sub>2</sub> and UV/Chlorine as AOPs for water treatment

#### UV/AOPs

**DBPs** formation Drinking Water Halogenated DBPs Treatment  $UV/H_2O_2$ UV/Chlorine VS AOX, HANs, HAAs, THMs ↔ •OH as oxidant ↔ •OH and reactive chlorine species (RCS) Change in toxicity ✤ Higher chance of Higher cost and Cytotoxicity, genotoxicity and Disinfection disinfection byproducts energy consumption oxidative stress response Oxidation (DBPs) Cytox, Nrf2, p53, p53+s9 Methodology

### **Research Goals**

• Comparing the performance of  $UV/H_2O_2$  and UV/Chlorine by assessing DBPs formation via chemical analysis and toxicity change using in vitro bioassays

Providing detailed comparison of UV-AOPs which could further act as a guide for their appropriate applications in various scenarios in drinking water treatment



concentration.

#### **Comparison of OH radical exposure**



AOX HAAs 100-30-UV fluence MMM AOBr fraction UV fluence mJ/cm<sup>2</sup> **—** 0 80-\_\_\_\_\_ 300 600 20ng/L ng/L 60 -**—** 1000 AOX, HAAS 40-10-20-- UI H202 5mg/L CI 5mg/L CI 5mg/L CI  $5mg|L H_2O_2 \\ 5mg|L G_1 H_2O_2 \\ 5mg|L G_1 H_2O_2 \\ 5mg|L H_2O_$ 

\* AOX

The degradation rates of pCBA during UV/Chlorine and

The result indicate that comparable levels of OH radical

exposure can be achieved with UV/Chlorine and UV/H2O2

processes when applying the same mass-based oxidant

**Figure 1**. Relative residual pCBA concentration as a function of UV fluence during

tested oxidant conditions (4 ppm  $Cl_2$  and 5 ppm H2O2).

 $UV/H_2O_2$  were comparable as a function of UV fluence in the

- The AOX formation was higher for UV/Chlorine compared to UV/H2O2
- For UV/Chlorine, the majority of AOX formation occurred during the first minute of dark chlorination, whereas only a minor increase in AOX formation was observed during chlorine photolysis
- $UV/H_2O_2$  showed a reduction in AOX that was pre-existing in the sample, as the UV dose increased





Figure 3. (a) Cytotoxicity and (b) oxidative stress response of the sand-filtered waters before and after treatments with UV/Chlorine and UV/ $H_2O_2$ 

#### Conclusions



**Figure 2.** Formation of DBPs during treatment of  $5mg/L H_2O_2$  or chlorine, coupled with 0~1000 mJ/cm<sup>2</sup> UV dose with and without 100ppb bromide spiking

## Acknowledgement

The proportion of AOBr increased following the addition of 100 ppb of bromide

#### THMs, HAAs, HANs

- Formation of THMs, HAAs, and HANs was significantly higher for UV/Chlorine compared to  $UV/H_2O_2$
- For UV/Chlorine, the DBP formation increased with increasing UV dose
- Addition of bromide had minor effect  $\bullet$ on the total formation of halogenated DBPs
- Formation of halogenated DBPs (AOX, THMs, HAAs, HANs) during UV/Chlorine treatment was significantly higher compared to  $UV/H_2O_2$  treatment, consistent with previous reports
- Assessment with *in vitro* bioassays, covering cytotoxicity, genotoxicity, and oxidative stress response, exhibited insignificant differences between UV/Chlorine and UV/H<sub>2</sub>O<sub>2</sub> treatments. This outcome contrasted with the significant difference observed in the chemical DBP analyses
- Research is on-going to assess the changes of overall toxicity during UV/Chlorine and UV/H<sub>2</sub>O<sub>2</sub> treatments by considering both volatile and non-volatile DBP mixtures

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## inspiring change

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